



Automatic Macro Inspection System

AMI-5700



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The AMI-5700 makes both high throughput and exceptional detection sensitivity very achievable. The aim of this device is to realize higher sensitivity and accuracy than previous models. It achieves high-speed measurement and inspection by performing batch imaging of the entire wafer surface. This is an innovative device that can perform inspection and measurement as a single unit.

Key Features

- Nikon's diffracted light detection system detects pattern variations along the Z-axis, especially focus error and poor coating, with high sensitivity. In addition, accurate recognition of the diffracted light only from the top pattern layer is possible, allowing defects in underlying patterns to be discriminated.
- High quality images with reduced chromatic aberration can be obtained by the newly developed optical system and improved collection mirror.
- An improved mirror tilting mechanism greatly contributes to the reduction of under-layer noise, realizing more accurate inspection, such as the accurate detection of changes in the top layer pattern.
- Detects particles and scratches as small as 5 μm by scattering inspection, achieving even higher sensitivity than previous models.
- Achieves high throughput of 180 wafers/hour, even when performing diffraction and scattering inspection as a batch inspection of the entire wafer. Also supports 3 load ports and enables efficient operation according to the line, greatly contributing to improved productivity.
- A high-speed measurement function has been implemented for the first time in the AMI series. CD measurement, film thickness measurement and focus measurement are possible at speeds that surpass previous methods.
- Complies with the RoHS directive and REACH regulations concerning the environment.
- A unique learning function utilizes AI image processing technology to quantify the characteristics of a good wafer.
- The versatile automatic recipe creation function allows even inexperienced operators to create optimal recipes in a short time.
- In addition to the Automatic Defect Classification (ADC) function, operators can specify their own rework criteria in a recipe in order to automate rework judgments.
- Hole process inspections are also supported.

Specifications

- Enables 3x, 2x, 1x nanometer lithography (supports EUV, DSA and Quad Patterning)
- Applicable for 3D Memory/LOGIC/CMOS image sensor devices
- Provided with pattern edge roughness (PER) function and mirror tilting optical system
- Inspection throughput: 180 or more wafers/hour (standard magnification: scattering and diffraction inspection or mirror reflection inspection)
- Measurement throughput: 25 wafers/25 minutes (when batch imaging of the entire wafer is implemented 3 times under different conditions with the shortest exposure time)
- Enables measurement of up to 75,000 points (26 mm \times 33 mm) in one capture.



WARNING

TO ENSURE CORRECT USAGE, READ MANUALS CAREFULLY BEFORE USING YOUR EQUIPMENT.

The export of this product is controlled by Japanese Foreign Exchange and Foreign Trade Law and International export control regime. It shall not be exported without authorization from the appropriate governmental authorities.

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